

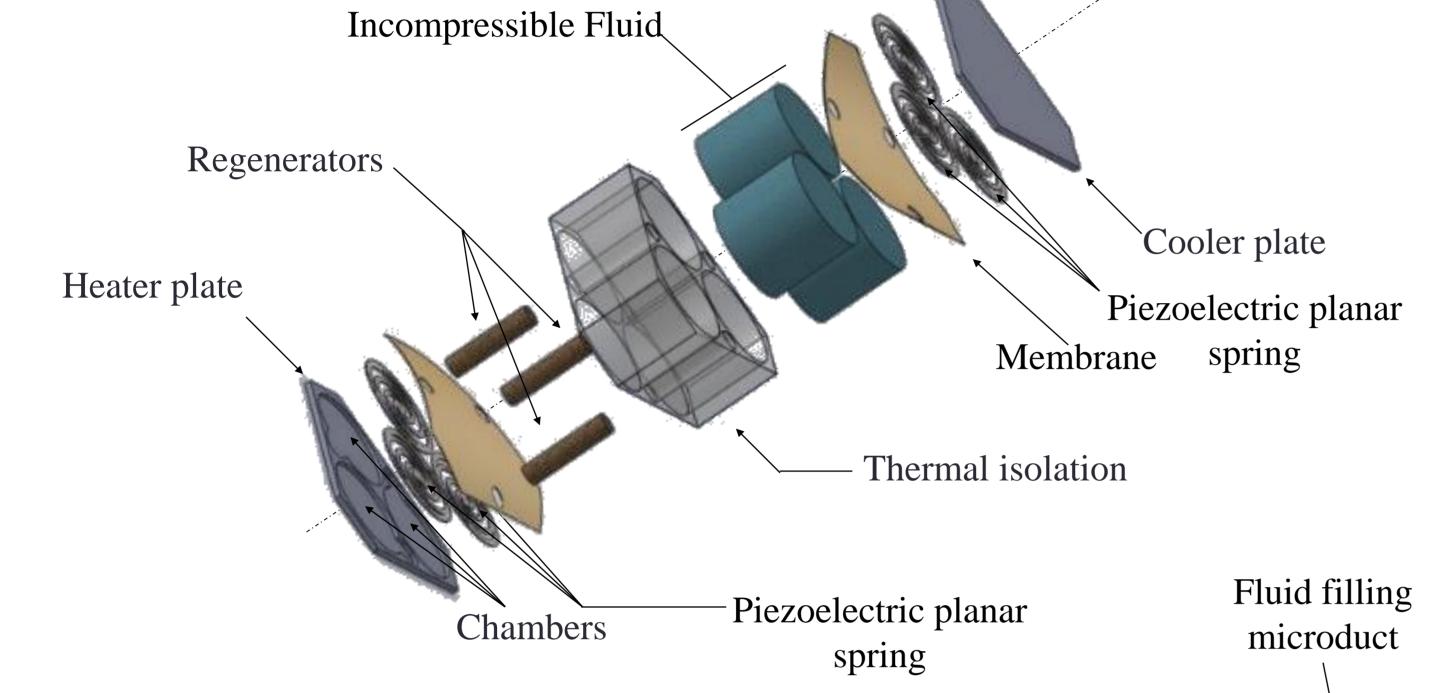
Hybrid Diaphragm development for A MEMS based Stirling engine

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Abstract: The paper describes the microfabrication of an innovative double acting Stirling engine for low temperature heat recovery. The usual pistons are replaced by hybrid RTV silicone - planar Si spring - fluid diaphragm (HFD). The proposed fabrication process ensures the fabrication of a free suspended RTV silicone membrane on silicon wafer, the sealing of membrane wafer with glass wafer and the incompressible fluid filling done at the wafer level.

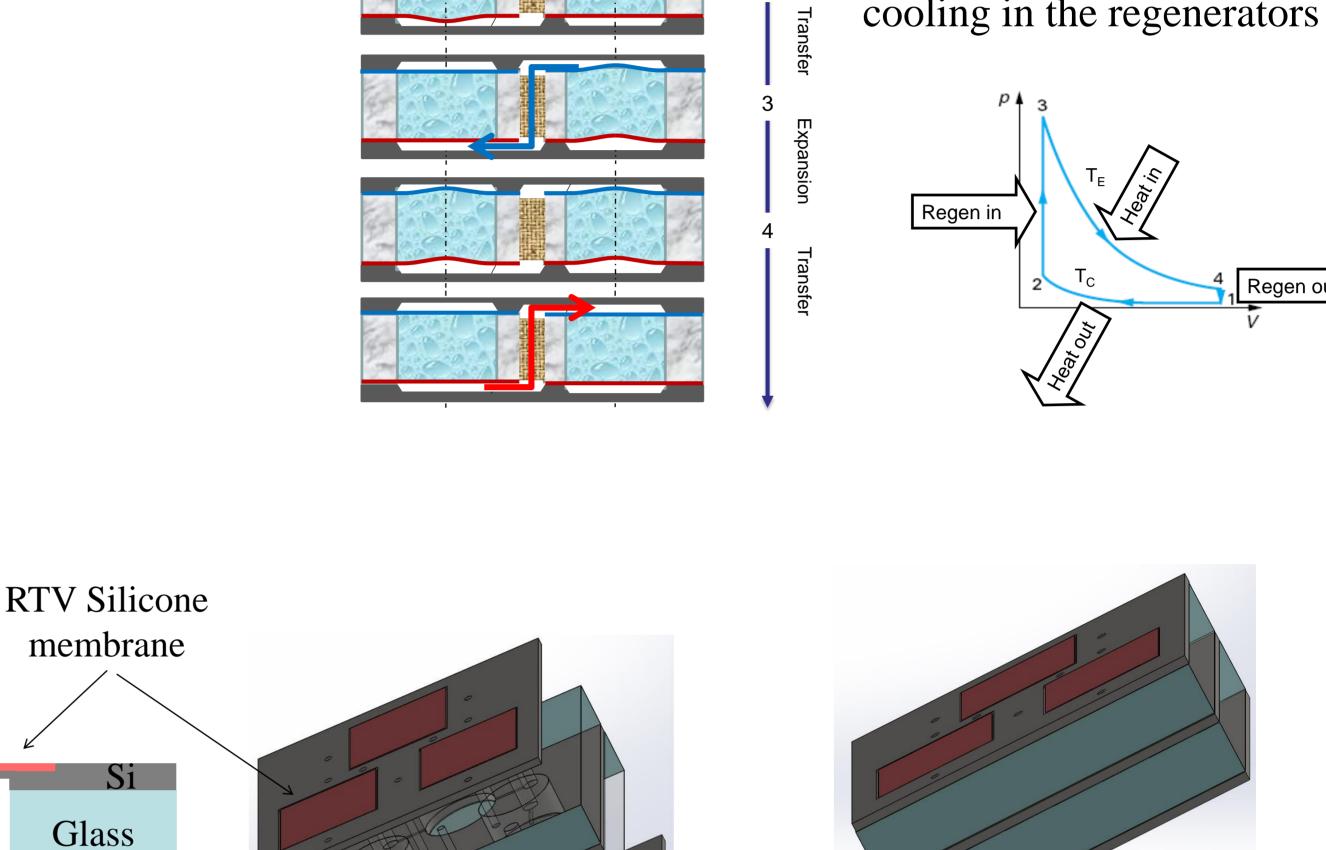
GENERAL ARCHITECTURE AND WORKING PRINCIPLE	T _{cold}	T	• Ideal Stirling cycle:
	2 2 2 2 2 2 2 2 2 2 2 2 2 2 2 2 2 2 2 2	1 <u>6</u>	- Isothermal compression and
 CAD view of the microStirling engine 	T _{hot}	mpress	expansion
		sion	- Constant volume heating and
	- 100 - 100	2	

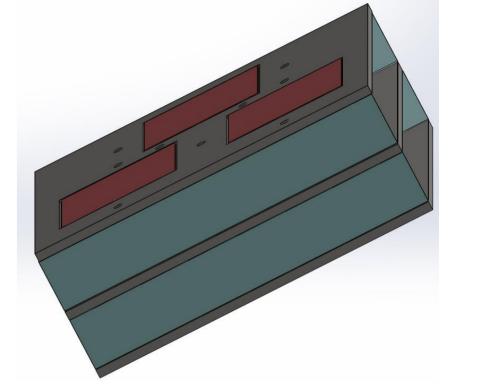


• Details of the HFD and technical requirements

- \circ Ø = 5 mm
- Incompressible fluid sealing
- No air bubble to ensure the proper dynamic characteristics Ο
- High quality factor
- Mechanical robustness for $20^{\circ}C \le T \le 150^{\circ}C$ Ο
- Thermal insulation Ο

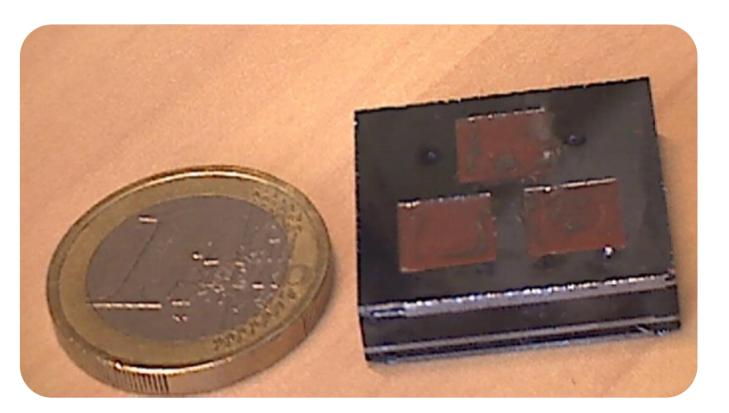
MICROFABRICATION





Regen out

Hybrid fluid diaphragm cluster Ο



I. Microfabricted RTV silicone membrane integrated on silicon wafer

DRIE of silicon

RTV silicone molding

DRIE of back to suspend the membrane

Optical micrograph of free suspended RTV silicone membrane



Fluid is filled in the cavity with pull-push method by creating a vacuum followed by low purging with nitrogen.

II. Wafer level fluid filling process

Vacuum/N2 Fluid(water/glycrine) Kaptone tape

Vacuum chamber

Si

Glass

Silicon planar

spiral spring

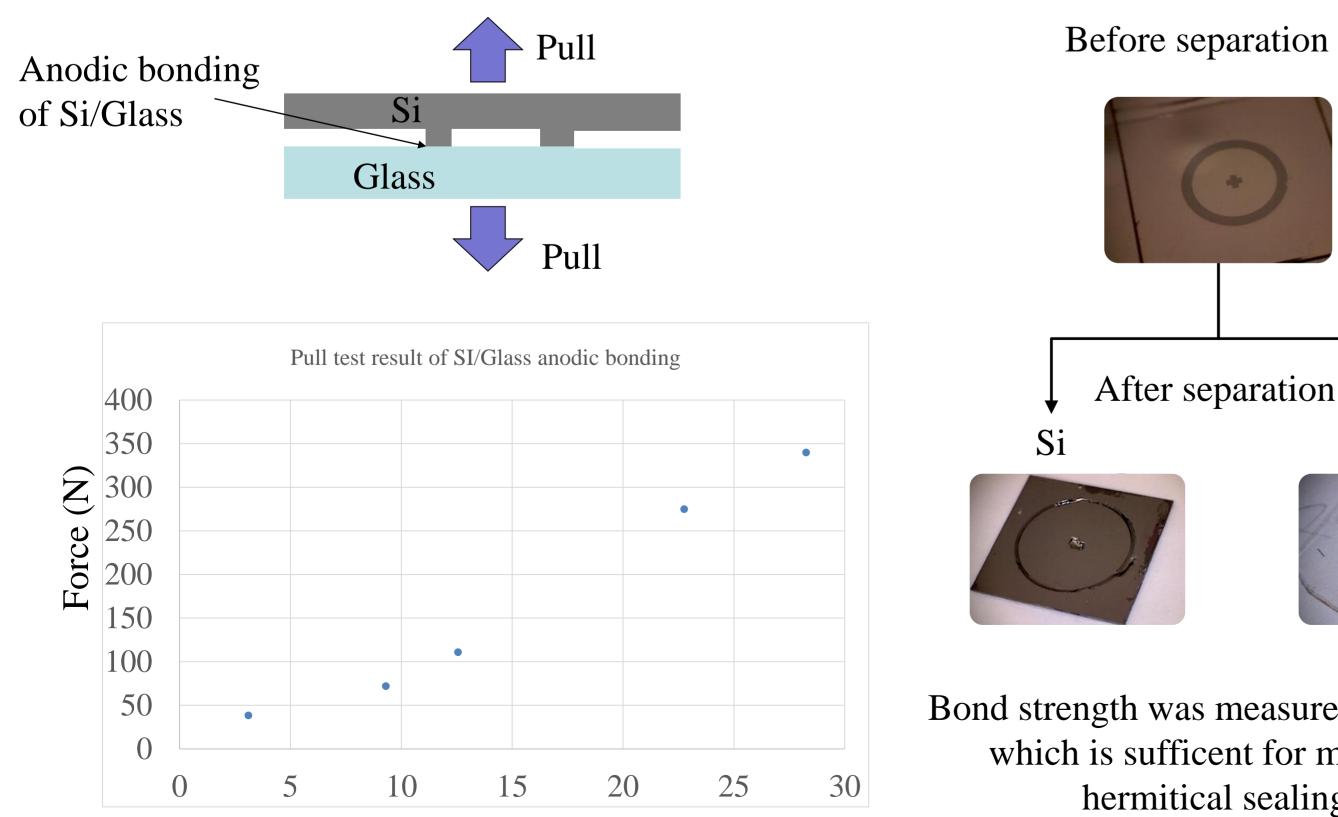


Air bubble in cavity when pressure in chamber is 800 mbar

No Air bubble in cavity when pressure in chamber is ≤ 500 mbar

CHARACTERIZATION

Pull test of low temperature (250°C) anodic bonding Ο



Conclusions

Wafer level fabrication of thin RTV silicone membrane is successfully demonstrated.

 \checkmark Multiple anodic bonding is validated and followed by the fabrication of an

After separation Glass

Bond strength was measured ~12 Mpa which is sufficent for machine hermitical sealing

HFD.

 \checkmark The process to fill the engine HFD has been tested with water and glycerine.

 \checkmark The low temperature anodic bonding is validated.

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Area (mm²)





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